



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : **Confirmation No. 1862**
Taku HIRAYAMA et al. : Attorney Docket No. 2005_0892A
Serial No. 10/537,290 : Group Art Unit 1752
Filed June 1, 2005 : Examiner Sin J. Lee
CHEMICAL-AMPLIFICATION TYPE : Mail Stop: AMENDMENT
SILICONE-BASED POSITIVE-WORKING
PHOTORESIST COMPOSITION

PETITION FOR EXTENSION OF TIME

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

THE COMMISSIONER IS AUTHORIZED
TO CHARGE ANY DEFICIENCY IN THE
FEES FOR THIS PAPER TO DEPOSIT
ACCOUNT NO 23-0975

Sir:

Petition hereby is made for a one month extension of time to respond to the communication of
October 3, 2007.

The fee of \$120.00 is

- (X) submitted herewith.
() to be charged to Deposit Account No. 23-0975. A duplicate copy of this Petition is
enclosed.
() Small entity status of this application is established by a Small Entity Status Assertion
which
() is enclosed.
() has been previously submitted.
() has been previously asserted.

Respectfully submitted,

Taku HIRAYAMA et al.

By: Matthew M. Jacob
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